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ABSTRACT OF THE DISCLOSURE

The present invention provides a nitride semiconductor room-temperature by which stable high power laser continuous-wave oscillation in fundamental mode is possible. A semiconductor laser diode comprising: a GaN layer; a first conductive type nitride semiconductor layer formed on said GaN layer and made of $Al_xGa_{1-x}N(0.04 \le x \le 0.08)$; a first conductive type clad layer formed on said first conductive type nitride semiconductor layer and made of nitride semiconductor; a core area formed on said first conductive type clad layer and made of nitride semiconductor, said core area including an active layer to emit light by electric current injection; and a second conductive type clad layer formed on said core area and made of nitride semiconductor.